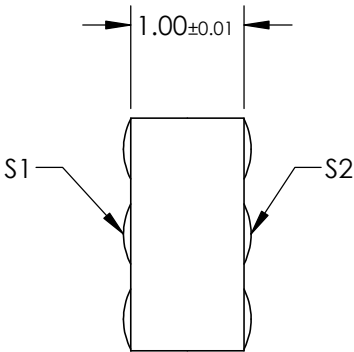
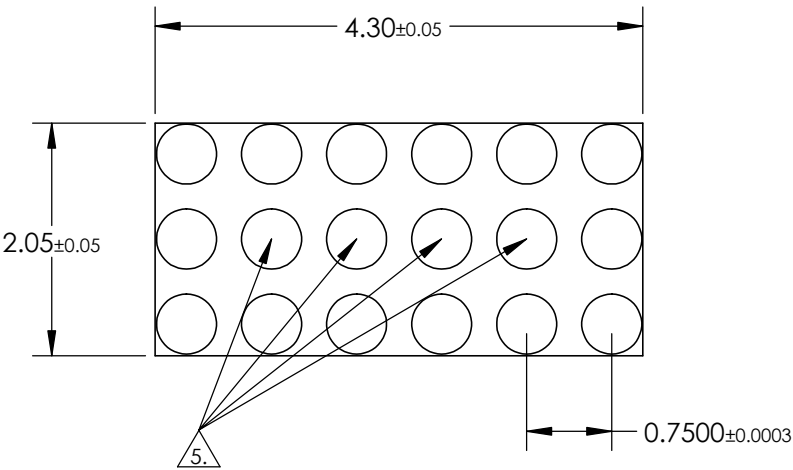
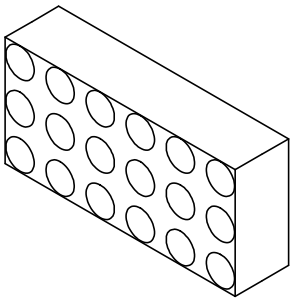


NOTES:

- 1. SUBSTRATE:
Fused Silica
- 2. COATING (APPLY ACROSS COATING APERTURE):
S1 & S2: R(AVG) ≤0.3% @ 1250 - 1620
- 3. WORKING DISTANCE (mm):
0.6
- 4. MODE FIELD DIAMETER (mm):
Source: 0.0092
Target: 0.25

5. ACTIVE LENSES CENTERED ON SUBSTRATE

6. ROHS: COMPLIANT



SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

**FOR INFORMATION ONLY:
DO NOT MANUFACTURE
PARTS TO THIS DRAWING**

Edmund Optics®

THIRD ANGLE PROJECTION		TITLE	4.30 x 2.05mm, 0.575 ROC, 750µm Pitch, Fused Silica, 1 x 4 Linear Microlens Array	
ALL DIMS IN	mm	DWG NO	21174	SHEET 1 OF 1